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DECOMPOSITION OF DIOXIRANES INDUCED BY DIALKYL ETHERS

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Abstract: Simple dialkyl ethers (*i.e.* diethyl or dihexyl ether), in addition to undergo oxidative cleavage by reaction with methyl(trifluoromethyl)dioxirane or dimethyldioxirane, induce the decomposition of these oxidation reagents in a concentration dependent manner. The identification of compounds derived from reactions with species such as $\text{CH}_3\cdot$ or $\text{CF}_3\text{CO}_2\cdot$ suggests that the above decomposition is a radical chain process.

Key words: Ether, radicals, dimethyldioxirane, methyl(trifluoromethyl)dioxirane.

The advantages of dioxiranes as oxidation reagents in organic synthesis, *i.e.* easy of preparation and manipulation, high reactivity under neutral conditions, broad scope of substrates and simple work-up procedures, account for their numerous applications reported during the last years. Thus, oxidation of heteroatoms, epoxidation of double bonds or oxygen insertion into C-H bonds are representative examples of the reactivity of these compounds ¹. Among dioxiranes, dimethyldioxirane (DMD) has been the most widely used reagent, although the unique reactivity exhibited by methyl(trifluoromethyl)dioxirane (TFMD) has led to remarkable and selective synthetic transformations ^{1c,2}.



Despite the oxidation properties of TFMD, its use has been somewhat restricted due to a "classical" problem encountered in its preparation. Thus, it was known that some commercially available 1,1,1-trifluoropropanone (TFP) batches did not afford TFMD when treated with caroate under the conditions described by Mello *et al.*³. Occasionally, the pale yellow solution containing the dioxirane could be collected at -70 °C, but the color disappeared when the temperature raised to approximately -20 °C, with the concomitant loss of the oxidation power. In addition, the TFP samples that did not give rise to stable TFMD solutions caused also the deactivation of DMD when added to acetone solutions of this compound, although this deactivation took place at a slower rate. These facts suggested the presence of an impurity in the fluorinated ketone which would be the species responsible for the observed decomposition of both dioxiranes. This impurity could not be removed from TFP either by distillation or by different drying procedures. However, when we performed a partition of TFP among water and CCl_4 (which is the method used by Adam *et al.* for obtaining TFMD solutions free from TFP ⁴), we observed that the impurity was concentrated into the organic layer, which allowed its identification by NMR and GC. The impurity resulted to be *diethyl ether* (Et_2O), probably arising from the method used for the preparation of TFP. The concentration of Et_2O in the fluorinated ketone sample was estimated within 1-2% (ca. 0.2 M, ¹H NMR) in the different batches analyzed. On the other hand, the addition of this amount of Et_2O to a stable solution of TFMD led to the immediate decomposition of this dioxirane, which confirmed our hypothesis ⁵. This

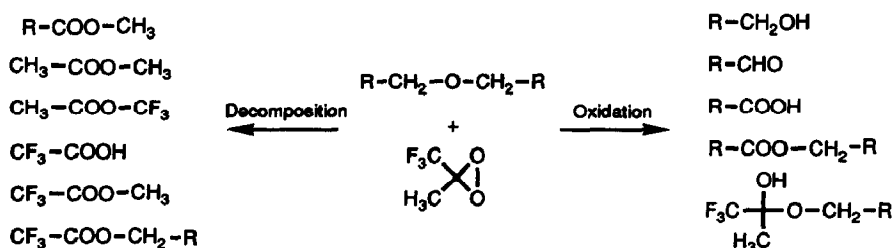
finding prompted us to study with a more detail the behaviour of TFMD in front of simple dialkyl ethers. For this purpose we chose Et₂O and dihexyl ether (Hex₂O) as model substrates, and the preliminary results obtained are also reported in the present communication.

Regarding the stability of dioxiranes, Singh and Murray reported that the thermal decomposition of DMD in solution of mixtures of different ketones leads to the formation of acetyloxyketones. A mechanism involving hydrogen atom abstraction from the ketones promoted by the radical species generated in the decomposition of DMD, with further reaction of the ketone radical intermediate with acyloxy radicals derived from homolysis of the dioxirane, would account for the formation of the observed esters ⁶. On the other hand, Adam *et al.* studied the thermal and photochemical induced decomposition of TFP-free solutions of TFMD. The detection of methyl and trifluoromethyl esters of acetic and trifluoroacetic acids supported the hypothesis of a radical chain process initiated by attack of CH₃ and CF₃ radicals over TFMD to give α-alkoxy-α-alkoxyl radical intermediates, which would afford the ester derivatives by β-alkyl fragmentation ⁴. More recently, the same group reported the decomposition of TFMD induced by catalytic amounts of iodide anion; in this case, a catalytic cycle takes place with the exclusive formation of TFP and superoxide ion ⁷.

Concerning the reaction of dioxiranes with ethers, Curci *et al.* reported that acetals and ethers are oxidized by dioxiranes through α-CH insertion. The selectivity found for the hydroxylation into C-H bonds α to the ether moiety suggested that the reaction proceeded through a non-radical pathway. Among the substrates studied, there was only one dialkylether, that is CH₃-(CH₂)₆-O-(CH₂)₆-CH₃, and the identified products from its reaction with DMD were heptanol, heptanal and heptanoic acid, by using a 1:2.2 substrate:DMD molar ratio ⁸.

In our case, we determined as a 1.5:10 dialkyl ether:TFMD molar ratio the relative concentration of either Et₂O or Hex₂O needed to induce the complete deactivation of this dioxirane (30 min at -20 °C). In respect to the products formed in this decomposition process, when an enough amount of Et₂O (0.2 mmol) was added to 1 ml of a 0.6 M solution of TFMD in TFP at -20 °C for achieving the complete deactivation of this dioxirane, the ¹H and ¹⁹F NMR analysis of the reaction mixture allowed the identification of ethanol, acetaldehyde, acetic acid, ethyl acetate, methyl acetate, trifluoroacetic acid, methyl trifluoroacetate, ethyl trifluoroacetate and trifluoromethyl acetate (Scheme I). While the first four components of this mixture could be originated from the oxidative cleavage of Et₂O (cf. ref. 8), the presence of the last compounds (*i.e.*, the fluorinated derivatives and methyl acetate) suggests that methyl and trifluoromethyl radicals had been also generated in the reaction medium. According to the results of Adam *et al.* mentioned above ⁴, the formation of these species occurs during the decomposition of the TFMD through a radical mechanism ⁹.

Scheme I



extent, through the radical chain mechanistic pathway shown in Scheme II for the case of TFMD.

In summary, we have presented different evidences that simple dialkyl ethers induce the decomposition of TFMD and DMD, and that this process takes place through the intervention of radical species derived from the ethereal substrate. The question that now emerges is related to the nature of these species; that is, whether they are originated from the ether itself or from a product derived from its oxidative cleavage. The different behavior observed in the deactivation of both dioxiranes suggests that the latter possibility could be more plausible. Investigations along this line are in progress in our laboratory ¹³.

Notes and References.

1. For recent reviews on these reagents, see a) Adam, W.; Curci, R.; Edwards, J. O. *Acc. Chem. Res.* **1989**, *22*, 205-211. b) Murray, R.W. *Chem. Rev.* **1989**, *89*, 1187-1201. c) Curci, R., in "Advances in Oxygenated Processes", A.L. Baumstark, Ed., JAI Press Inc., London, **1990**, pp 1-60. d) Adam, W.; Hadjiarapoglou, L. P.; Curci, R.; Mello, R. in *Organic Peroxides*; W. Ando, Ed.; Wiley, New York; **1992**, Chapter 4, pp 195-219.
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5. It should be pointed out that the different assays carried out to induce the decomposition of TFMD were performed using small (up to millimol range) amounts of reagents. In some cases, the observed decomposition processes were rapid, but not violent. However, the results reported herein advise for caution when handling dioxiranes in the presence of ethers.
6. Singh, M.; Murray, R.W. *J. Org. Chem.* **1992**, *57*, 4263-4270.
7. Adam, W.; Asensio, G.; Curci, R.; Gonzalez-Nuñez, M.E.; Mello, R. *J. Am. Chem. Soc.* **1992**, *114*, 8345-8349.
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9. It is worth of noting that solutions of TFP containing a 2% of Et₂O did not show the presence of these fluorinated and non fluorinated derivatives by NMR. On the other hand, when a conventional oxidation reaction with TFMD, such as epoxidation of *cis*-stilbene, was performed, the analysis of the crude reaction mixture showed only the presence of the expected epoxide and TFP. This result indicates that when TFMD acts as oxidation reagent, it does not lead to the formation of compounds derived from the generation of methyl or trifluoromethyl radical intermediates.
10. Adam, W.; Bialas, J.; Hadjiarapoglou, L. *Chem. Ber.* **1991**, *124*, 2377.
11. Preliminary assays carried out with different ethereal compounds showed that dimethoxyethane, dioxane or *t*butyl methyl ether did not induce the decomposition of DMD when tested under the same conditions. Conversely, THF afforded similar results to those observed for Et₂O.
12. The assay was performed as follows: to 1 ml of DMD soln. in acetone (75-85 mM) it was added 1 ml of an acetone soln. of Et₂O at the appropriate concentration, and the mixture was maintained at 0 °C, in the dark. Aliquots were taken at the given periods of time and DMD concentration was determined by using a GC analytical method based on the epoxidation of methyl citronellate in the presence of nitrobenzene as internal standard.
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